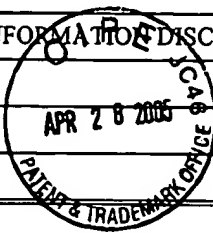


U.S. Department of Commerce, Patent and Trademark Office				Atty Docket No.: RAP0001P1US		Application No.: 09/491,461	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT				Applicant(s): Paul Dagum; Thomas A. Chavez			
Filing Date: January 26, 2000				Group Art Unit: 3623			



U.S. Patent Documents							
*Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate	
	AA						
	AB						
	AC						
	AD						
	AE						
	AF						
	AG						
	AH						

Foreign Patent Documents								
							Translation	
	Document	Date	Country	Class	Subclass	Yes	No	
	AI							
	AJ							
	AK							

OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)		
<div style="font-size: 2em; margin-top: 20px;">dwd</div>	<div style="font-size: 2em; margin-top: 20px;">↓</div>	<div>AL BASS, Frank M., <i>A New Product Growth For Model Consumer Durables</i>, Management Science, Vol. 15, No. 5, January 1969, pp. 216-227.</div> <div>AM DAGUM, Camilo, <i>Structural Permanence: Its Role in the Analysis of Structural Dualisms and Dependences and for Prediction and Decision Purposes</i>, The Economics of Structural Change Volume 1, Harald Hagemann et al., eds., Edward Elgar Publishing, 1969, pp. 211-235.</div> <div>AN MAHAJAN, Vijay, MULLER, Eitan, and BASS, Frank M., <i>New-Product Diffusion Models</i>, Chapter 8, Handbooks in OR & MS, Vol. 5, J. Eliashberg and G.L. Lilien, eds., Elsevier Science Pubs., B.V., 1993, pp. 349-408.</div> <div>AO HANSSENS, Dominique M. and LEONARD, J. Parsons, <i>Econometric and Time-Series Market Response Models</i>, Chapter 9, Handbooks in OR & MS, Vol. 5, J. Eliashberg and G.L. Lilien, eds., Elsevier Science Pubs., B.V., 1993, pp. 409-464.</div>

Examiner: <u>Beth Van Doren</u>	Date Considered: <u>8/10/05</u>
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.